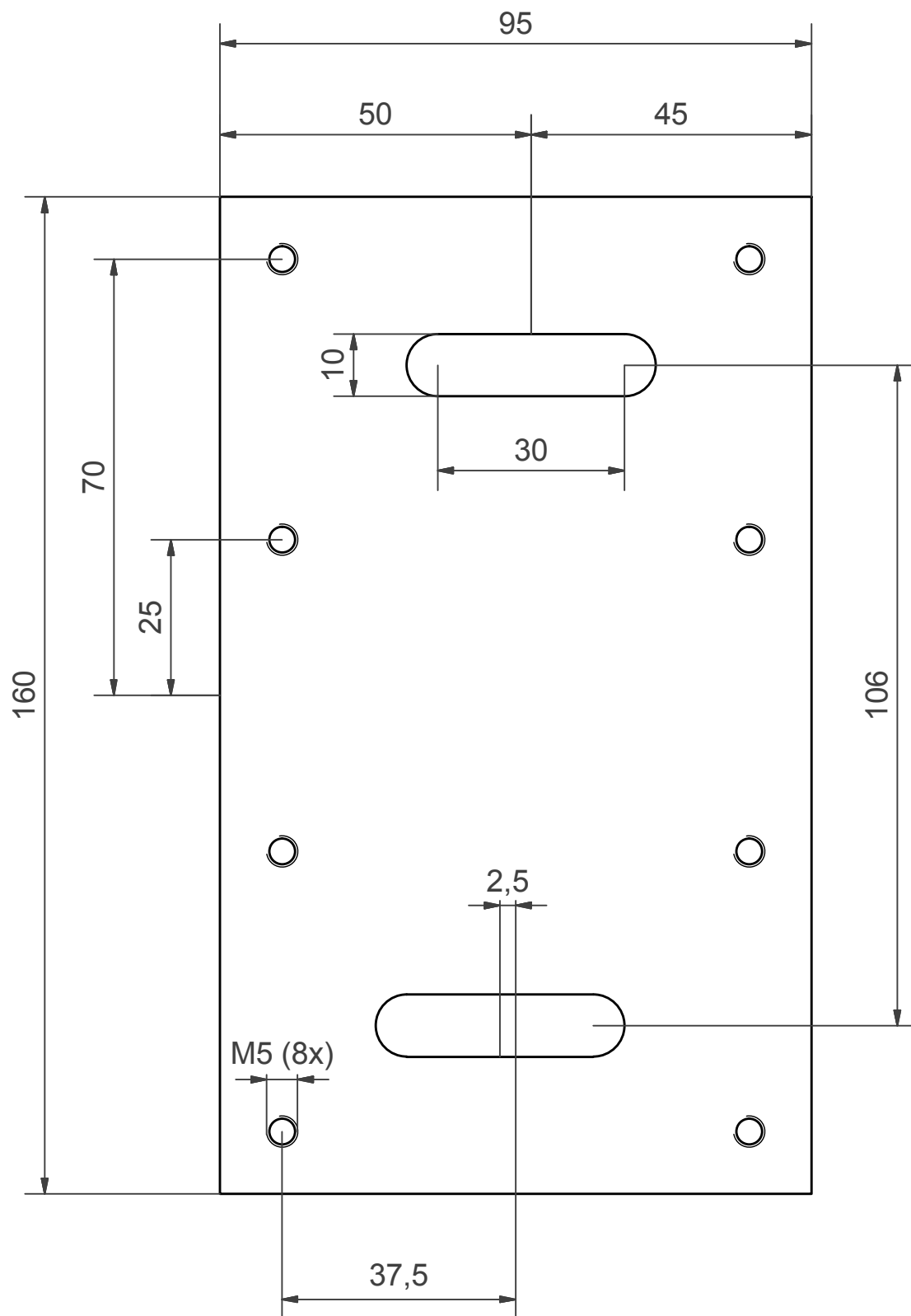
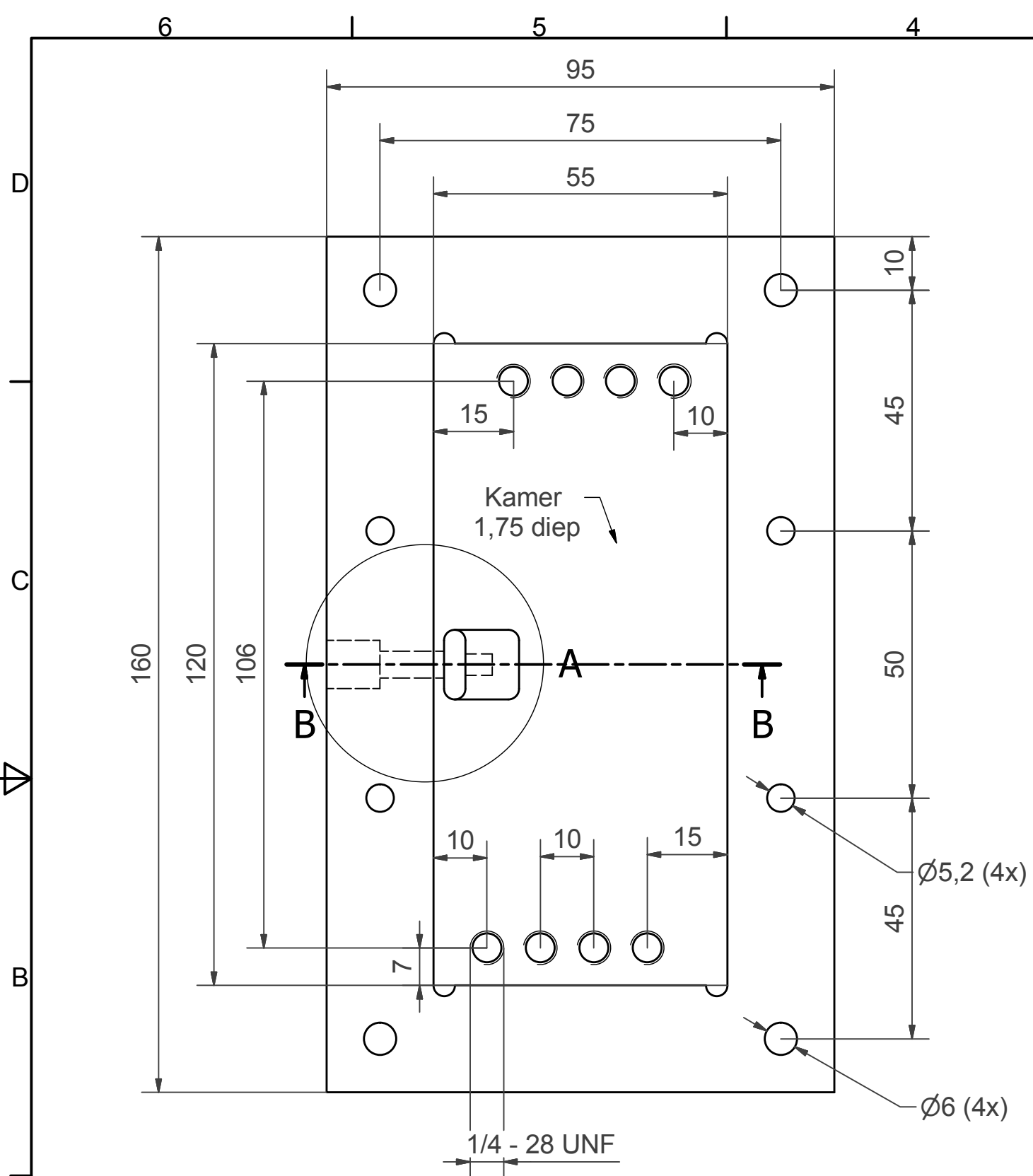
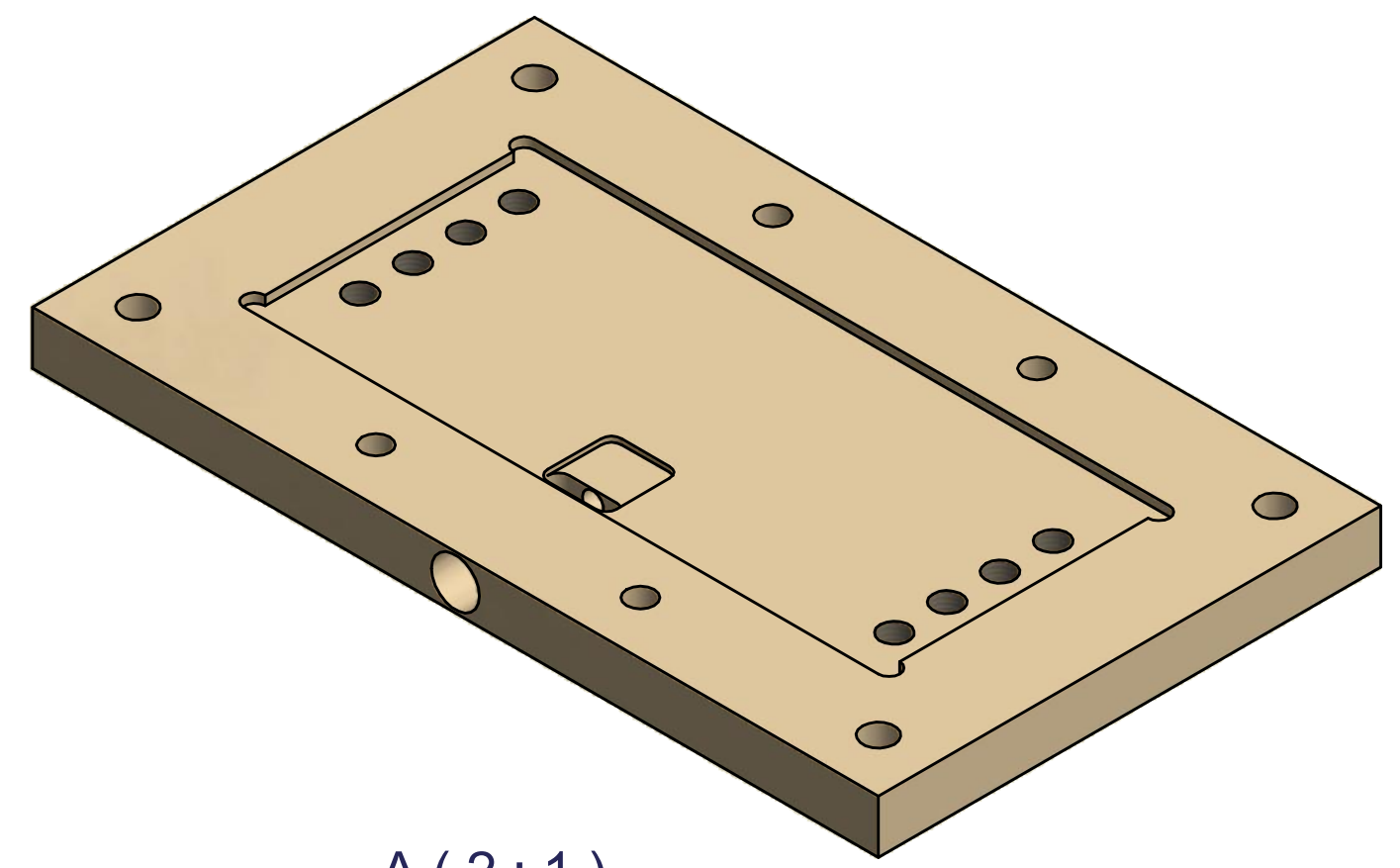
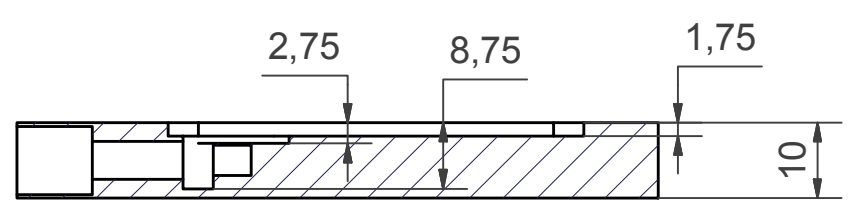




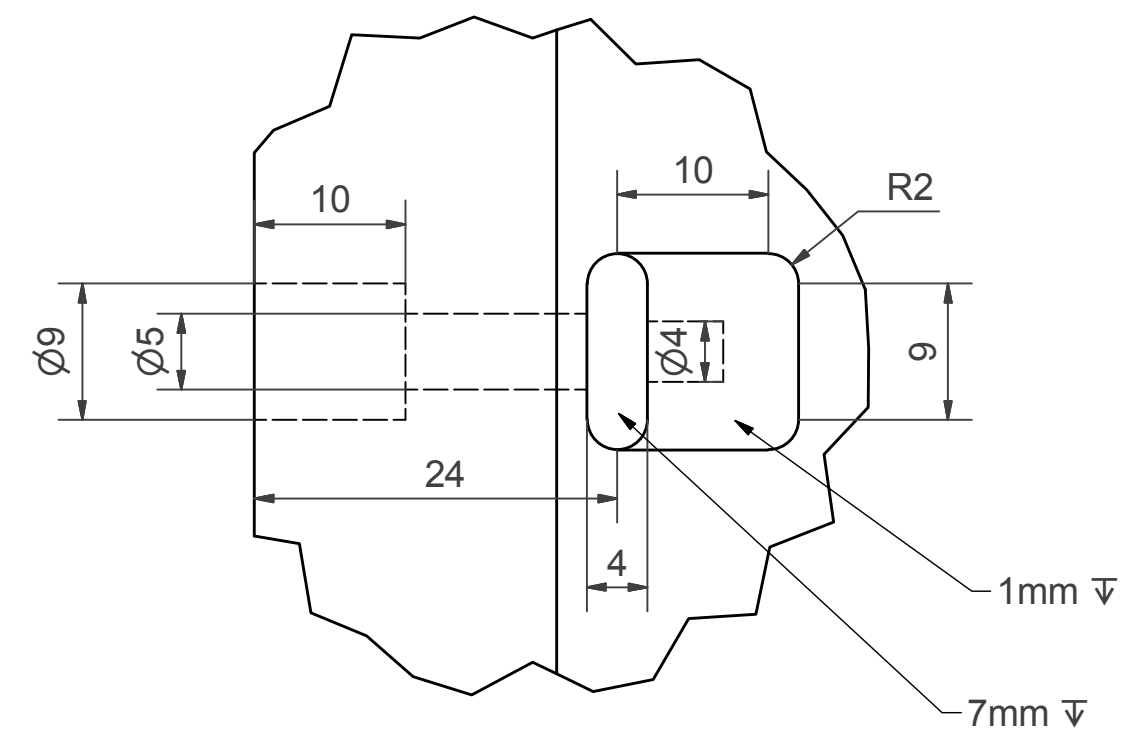
MAATTOLERANTIES, TENZIJ ANDERS VERMELD: $\pm 0,2$ mm HOEKTOLERANTIES, TENZIJ ANDERS VERMELD: $\pm 1^\circ$		PROJECTIE 	BENAMING:		
Technische Universiteit Eindhoven University of Technology Equipment & Prototype Center		AANTAL:	MATERIAAL:		A4
		SCHAAL:		PROJECTNUMMER :	
		GET.:			
		DATUM: 28-7-2017		REVISIE:	



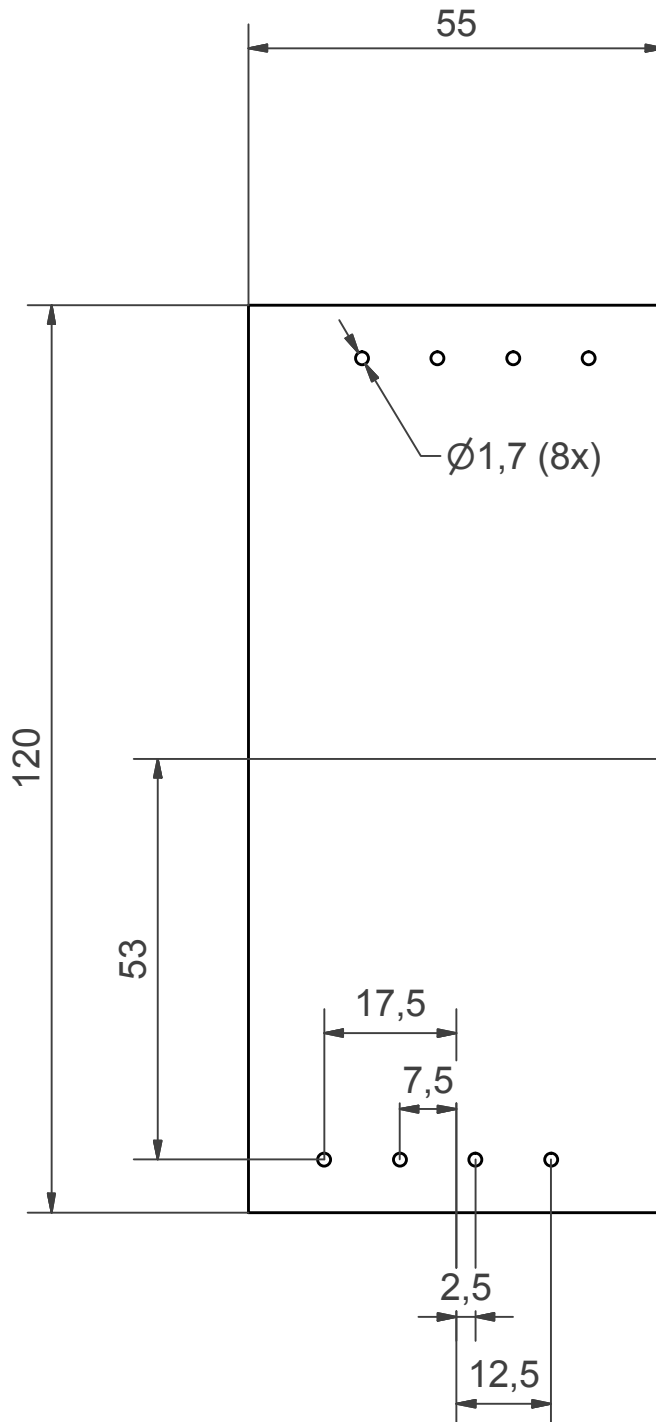
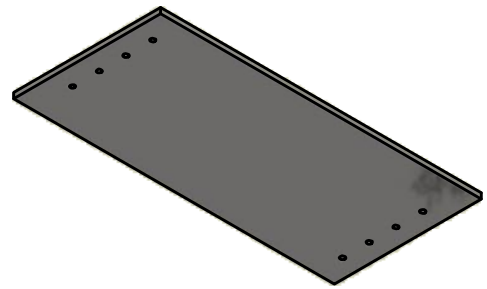
B-B (1 : 1)



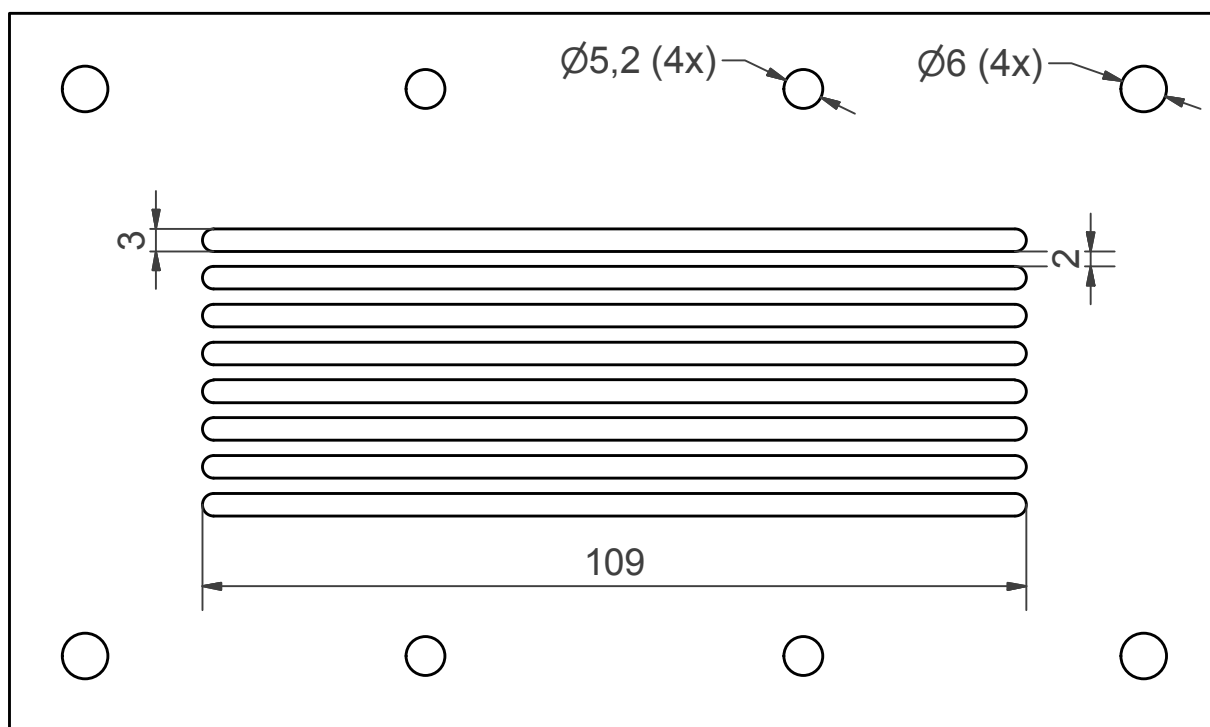
A (2 : 1)



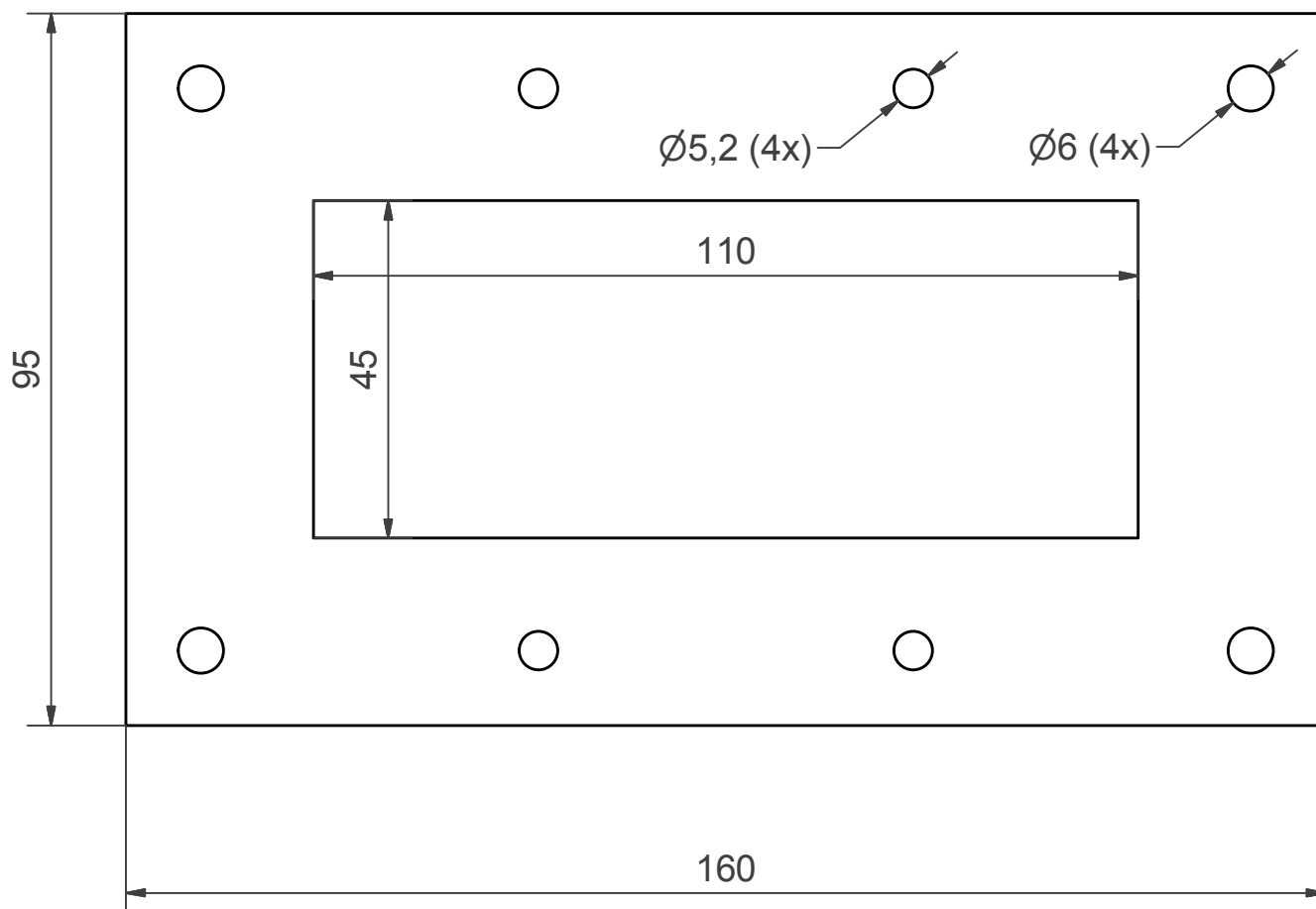
MAATTOLERANTIES, TENZIJ ANDERS VERMELD: $\pm 0,2$ mm HOEKTOLERANTIES, TENZIJ ANDERS VERMELD: $\pm 1^\circ$		PROJECTIE	BENAMING: PTFE plate Electrochemische Microreactor			
 Technische Universiteit Eindhoven University of Technology Equipment & Prototype Center		AANTAL: 2	MATERIAAL: PTFE		PROJECTNUMMER :	
		SCHAAL:			A3	
		GET.: W Kuip				
DATUM: 28-7-2017			REVISIE:			

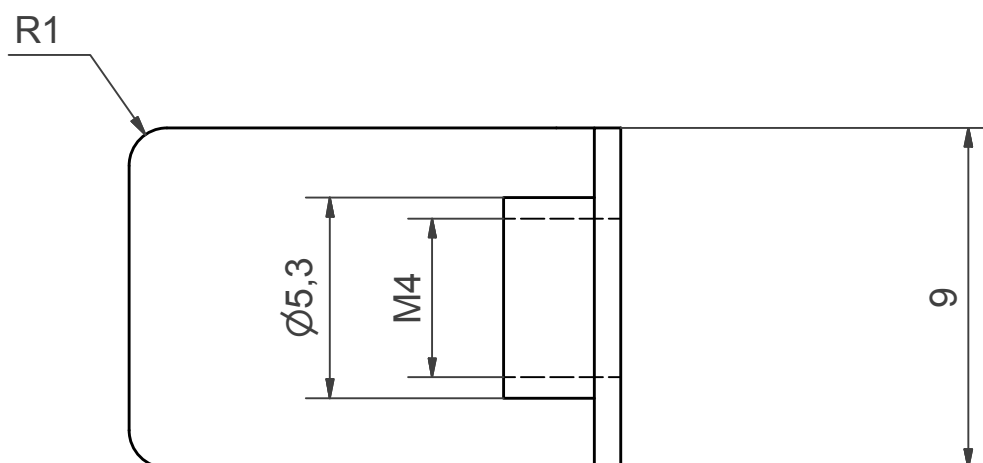
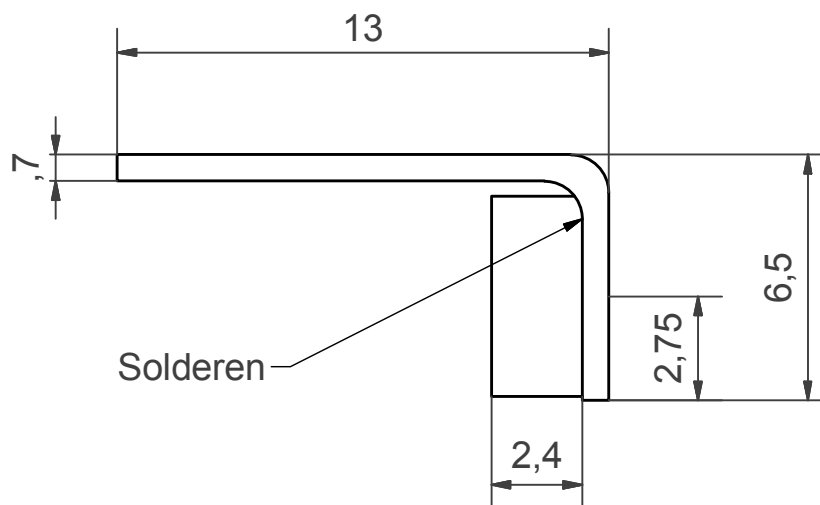
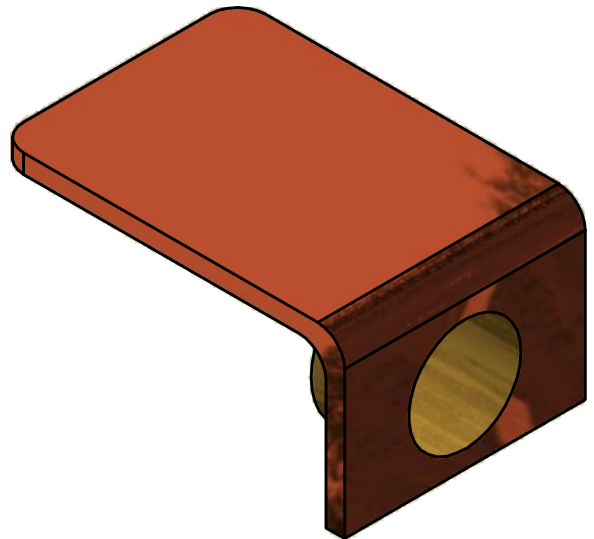


MAATTOLERANTIES, TENZIJ ANDERS VERMELD: $\pm 0,2$ mm HOEKTOLERANTIES, TENZIJ ANDERS VERMELD: $\pm 1^\circ$		PROJECTIE		BENAMING:			
Technische Universiteit Eindhoven University of Technology Equipment & Prototype Center		AANTAL:		MATERIAAL:		A4	
		SCHAAL:		PROJECTNUMMER :			
		GET.:					
		DATUM: 28-7-2017		REVISIE:			



Teflon: ieder model 5 st 0,5 mm dik en 0,25 mm dik (totaal 20 st)





MAATTOLERANTIES, TENZIJ ANDERS VERMELD: $\pm 0,2$ mm HOEKTOLERANTIES, TENZIJ ANDERS VERMELD: $\pm 1^\circ$		PROJECTIE 	BENAMING: contact strip Elektrochemische Microreactor									
 Technische Universiteit Eindhoven University of Technology Equipment & Prototype Center			AANTAL: 2		MATERIAAL: Fosforbrons							
			SCHAAL:				PROJECTNUMMER :				A4	
			GET.: W. Kuip									
			DATUM: 26-1-2018				REVISIE:					